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| Form PTO-1 (Rev. 8-83) | U.S.Department of Commerce Patent and Trademark Office | | Atty Docket 0756-2351 | | Serial No. 09/932,935 | | |
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| INFORMATION DISCLOSURE STATEMENT | | | Applicants: Shunpei YAMAZAKI et al. | | | | |
| . , | PE | | Filing Date: August 21, 2001 | | Group Art Unit: 2812 | | |
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| *EXAMIN | JER: Initial if citation considered, whether | r or not citation | is in conformance with MP | EP 609; Drav | w line through | citation if | |
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epartment of Commerce Form PTO-1449 Serial No. 09/932,935 11 Atty Docket 0756-2351 Patent and Trademark Office (Rev. 8-83) Applicants: Shunpei YAMAZAKI et al. INFORMATION DESCLOSURE STATEMENT **Group Art Unit: 2812** Filing Date: August 21, 2001 **U.S. PATENT DOCUMENTS** Filing Date Name Class Subclass Date Document Number Examiner (if appropriate) Initial 07/08/1986 Miyao et al. 4,599,133

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Sheet 1 of 1

Form PTO-1449 U.S. Department of Commerce Attorney Docket No: 740756-2351 Serial No. Not Yet Assigned (Rev. 8-83) Patent and Trademark Office INFORMATION DISCLOSURE STATEMENT (Use several sheets if necessary) Applicant: Shunpei YAMAZAKI et al. Filing Date: August 21, 2001 Group: 28 **U.S. PATENT DOCUMENTS** Examiner Document Number Date Name Class Subclass Filing Date Initial (if appropriate) 5,612,250 03/18/1997 Ohtani et al. 5,543,352 08/06/1996 Ohtani et al. 5,895,933 04/20/1999 Zhang et al. 5,882,960 03/16/1999 Zhang et al. 6,051,453 04/18/2000 Takemura 5,953,597 09/14/1999 Kusumoto et al. 5,561,081 10/01/1996 Takenouchi et al. 5,897,799 04/27/1999 Yamazaki et al. 6,002,101 12/14/1999 Yamazaki et al. 5,968,383 Yamazaki et al. 10/19/1999 5,900,980 05/04/1999 Yamazaki et al. 6,038,075 03/14/2000 Yamazaki et al. 5,959,779 09/28/1999 Yamazaki et al. 6,002,523 12/14/1999 Tanaka FOREIGN PATENT DOCUMENTS Document Number Date Country Class Subclass _Translation Yes No 07-161634 06/23/1995 Japan Abstract 07-321339 12/08/1995 Japan Abstract 07-131034 05/19/1995 Japan Abstract OTHER DOCUMENTS (Including Author, Title, Date, Pertinent Pages, Etc.) Specification and Drawings for Patent Application Serial No. 09/610,637, "Laser Irradiation Apparatus, Laser Irradiation Method, Semiconductor Device, and Method of Manufacturing a Semiconductor Device". Examiner Date Considered *EXAMINER: Initial if citation considered, whether or not citation is in conformance with MPEP 609; Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.